

Date: April 10, 2007

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| U.S. DEPARTMENT OF COMMERCE (REV. 05/03) PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE CITATION (Use several sheets if necessary) | | | | ATTY. DOCKET NO. BDL-487XX | | APPLICATION NO. 10/549,444 | |
| | | | | APPLICANT: Eric Sion et al. | | | |
| | | | | FILING DATE June 19, 2006 | | TC ART UNIT 1762 | |
| U.S. PATENT DOCUMENTS | | | | | | | |
| EXAMINER INITIAL | | DOCUMENT NUMBER | PUBLICATION/ ISSUE DATE | NAME | CLASS | SUBCLASS | FILING DATE |
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| *EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | | | | | | | |

CLG/laf/350375.1 (refs. enc.)

REFERENCES WERE CITED IN INTERNATIONAL SEARCH REPORT IN PCT/FR2004/001009